

Module – II.1

Carrier Diffusion

Diffusion Current:

If there is a gradient of concentrations of carriers, they can move by diffusion determined by Fick's Laws of Diffusion. This gives diffusion current density, J^{diff}.

In metals, as conductivity is high diffusion is not important, but low conductivity and the ease of creating non-uniform carrier densities in semiconductors, diffusion an important process.

For electrons and in one dimension, $J_n^{diff} = qD_n \frac{dn}{dx}$ For holes, $J_p^{diff} = -qD_p \frac{dp}{dx}$

'q' is the elementary charge (+1.6 × 10^{-19} C), and $D_n \& D_p$ are called the electron & hole diffusion constant.



For positive dn/dx(*n* increases as *x* increases) and positive dp/dx, electrons and holes diffuse to the left (toward the lower concentration point).

Since electrons carry negative charge, the diffusion current flows to the *right*.

But since holes are positively charged, the hole current flows to the *left*, the current is negative. Current through a semiconductor can flow through drift and/or diffusion. So total current is given as:-

$$\begin{split} J_n &= J_{n,\text{drift}} + J_{n,\text{diffusion}} = qn\mu_n \mathcal{E} + qD_n \frac{\mathrm{d}n}{\mathrm{d}x} \\ J_p &= J_{p,\text{drift}} + J_{p,\text{diffusion}} = qp\mu_p \mathcal{E} - qD_p \frac{\mathrm{d}p}{\mathrm{d}x} \\ J &= J_n + J_p \end{split}$$

In three dim.

$$J_{n} = electron current$$
$$= J_{n}^{drift} + J_{n}^{diff} = qn\mu_{n}E + qD_{n}\nabla n$$

$$\mathbf{\&} \mathbf{J}_{p} = hole \, current = \mathbf{J}_{p}^{drift} + \mathbf{J}_{p}^{diff}$$
$$= qp\mu_{p} \mathbf{E} - qD_{p} \nabla p$$

When a voltage is applied across a piece of semiconductor



➤A positive voltage raises the potential energy of a positive charge and lowers the energy of a negative charge. It therefore lowers the energy diagrams since the energy diagram plots the energy of an electron (a negative charge)

➢So energy diagram is lower (at the left) where the voltage is higher. The band diagram is higher where the voltage is lower.

➤The electrons roll downhill like stones in the energy band diagram and the holes float up like bubbles.

Graded Impurity Distribution

Let a semiconductor is non-uniformly doped with donor impurity atoms & the semiconductor is in thermal equilibrium.
 So the Fermi energy level is constant.
 The doping concentration decreases as 'x' increases.

There will be a diffusion of majority carrier electrons from the region of higher conc. to low conc. (to right).
 Negative electrons leaves behind positively charged donor ions. So separation of positive and negative charge induces an electric field in +x direction.

➢When equilibrium is reached, the induced electric field prevents any further separation of charge.



$$V = \frac{1}{e} (E_F - E_{Fi})$$

So electric field

$$\mathbf{E} = -\frac{dV}{dx} = \frac{1}{e} \frac{dE_{Fi}}{dx}$$

If electron concentration is almost equal to the donor impurity concentration

$$n_{0} = n_{i} \exp\left[\frac{E_{F} - E_{Fi}}{kT}\right] \approx N_{d}(x)$$

$$\Rightarrow E_{F} - E_{Fi} = kT \ln\left(\frac{N_{d}(x)}{n_{i}}\right)$$

$$\Rightarrow -\frac{dE_{Fi}}{dx} = \frac{kT}{N_{d}(x)} \frac{dN_{d}(x)}{dx}$$

$$\Rightarrow E_{x} = -\left(\frac{kT}{e}\right) \frac{1}{N_{d}(x)} \frac{dN_{d}(x)}{dx}$$

Einstein Relation:

$$J_n = J_n^{drift} + J_n^{diff} = en\mu_n \mathbf{E} + eD_n \frac{dn}{dx}$$

At equilibrium, $J_n = 0$

$$J_{n} = en\mu_{n}E + eD_{n}\frac{dn}{dx} = 0$$

If $n \approx N_{d}$
$$J_{n} = e\mu_{n}N_{d}(x)E + eD_{n}\frac{dN_{d}(x)}{dx} = 0$$

$$0 = -e\mu_n N_d(x) \left(\frac{kT}{e}\right) \frac{1}{N_d(x)} \frac{dN_d(x)}{dx} + eD_n \frac{dN_d(x)}{dx}$$
$$D_n = kT$$

$$\frac{\omega_n}{\mu_n} = \frac{\omega}{e}$$

Similarly for hole current

$$\frac{D_p}{\mu_p} = \frac{kT}{e}$$

 $\frac{D}{\mu} = \frac{k_B T}{q} \Leftarrow Einstein Relation$

In semiconductors,
$$\frac{D_n}{\mu_n} = \frac{D_p}{\mu_p} = \frac{k_B T}{q} \cong 25.87 \text{ mV}$$
 at 300K

As the mobilities are strong functions of temperature, the diffusion coefficients are also strong functions of temperature. Major temperature effects are a result of lattice scattering and ionized impurity scattering processes.

	μ _n	D _n	μ_{p}	D _p
Si	1350	35	480	12.4
GaAs	8500	220	400	10.4
Ge	3900	101	1900	49.2

Using Einstein Relation
$$\frac{D}{\mu} = \frac{k_B T}{q}$$

$$J_{n} = qn\mu_{n}E + qD_{n}\nabla n = q\mu_{n}\left[nE + \frac{k_{B}T}{q}\nabla n\right]$$
$$J_{p} = qp\mu_{p}E - qD_{p}\nabla p = q\mu_{p}\left[pE - \frac{k_{B}T}{q}\nabla p\right]$$

 $J_{total} = J_n + J_p = qn\mu_n \mathbf{E} + qp\mu_p \mathbf{E} + qD_n \nabla n - qD_p \nabla p$

 $=q(n\mu_n+p\mu_p)\mathbf{E}+k_BT(\mu_n\nabla n-\mu_p\nabla p)$